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Abstract: (12 font Bold)

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Keywords: (12 font - Italic)

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Introduction: (12 font Bold)

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In Literature Survey the format can be as following:

[Dubuc, 2018 / Liu et al., 2020 / Zhou and Huang (2022)]

Material & Methods: (12 font Bold)

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Results and Discussion: (12 font Bold)

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Conclusion: (12 font Bold)

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Zhou, W. and Huang, X. Cold atmospheric pressure plasmas applications in dentistry, Plasma Process. Polym., vol. 19, no. 8, 2022.

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